

Monday Afternoon, October 19, 2015

2D Materials Focus Topic

Room: 212C - Session 2D+EM+MC+MS+NS-MoA

2D Materials: Devices and Applications

Moderator: Joshua Goldberger, The Ohio State University, Arend van der Zande, University of Illinois at Urbana Champaign

2:20pm **2D+EM+MC+MS+NS-MoA1 Designer Materials from the Assembly of 2D Layered Heterostructures, Cory Dean, Columbia University** **INVITED**

The capability to assemble two-dimensional (2D) materials into layered heterogeneous structures presents an exciting new opportunity in materials design. For example, encapsulating graphene with hexagonal BN yields enhanced transport properties with reduced environmental sensitivity, and allows for complex band structure engineering. This has enabled graphene to be exploited as a model experimental platform to study a wide range of fundamental physics arising both from conventional single-particle considerations, as well as more exotic emergent behaviour in the strongly interacting regime. Graphene however represents just one of a larger subset of layered materials, which are now receiving growing attention due to their diverse array of intrinsic properties. The opportunity to “mix and match” these disparate crystals to realize fundamentally new hybrid material properties provides an almost unbounded new direction as we look for quantum materials beyond graphene. In this talk I will outline some of the fundamental questions, and technical challenges facing these efforts and highlight some of our recent innovations in this direction. Implications for the development of new device geometries and scientific pursuits will be discussed.

3:00pm **2D+EM+MC+MS+NS-MoA3 Structural Semiconducting-to-Metallic Phase Transition in Monolayer Transition Metal Dichalcogenides Induced by Electrostatic Gating, Yao Li, K.-A. Duerloo, E.J. Reed, Stanford University**

Dynamic electrical control of conductivity in two-dimensional (2D) materials is one of the most promising schemes for realizing energy-efficient electronic devices. Monolayer transition metal dichalcogenides (TMDs) are 2D materials that can exist in multiple crystal structures, each of different electrical conductivity. Using density functional approaches, we discover that a structural semiconducting-to-metallic phase transition in some monolayer TMDs can be driven by electrical stimuli, including change of charge density and bias voltage. We find that a bias voltage approximately 0.5–1 V can trigger the phase transition in MoTe_2 , while a larger voltage is required for the transition in other monolayer TMDs. The threshold bias voltage is strongly influenced by the substrate on which the monolayer is placed. Carefully choosing the substrate could greatly reduce the threshold bias voltage for the phase transition, and therefore consume much less energy, suggesting potential applications in electronics with very high energy efficiency. The dynamic control of this semiconducting-to-metallic phase transition can be achieved utilizing standard electronic devices like the electrostatic gating employed in a field-effect transistor. We have also calculated the phase boundary of a reported metallic-to-metallic phase transition in TaSe_2 to compare with earlier STM experimental results and reasonable agreement is observed. Our findings open up the possibility of manufacturing ultrathin flexible two-dimensional phase change electronic devices with potential for higher energy efficiency than conventional electronic devices.

3:20pm **2D+EM+MC+MS+NS-MoA4 Use of Voltage-Contrast and Dynamical XPS for Characterization of Graphene-Based Devices in Operation, Sefik Suzer, Bilkent University, Turkey**

A noncontact chemical and electrical technique of XPS is performed to investigate a number of devices under operation. The main objective of the technique is to trace chemical and location specified surface potential variations as shifts of the XPS peak positions under operating conditions. To implement the measurements we apply D.C. (Voltage-Contrast) and/or A.C. (Dynamical) voltage biases externally to the sample, while recording XPS data. Accordingly, we extract chemically resolved static and/or time-resolved information related with certain electrical properties of materials and devices made from them. Details of the technique and applications to a number of graphene-based devices, configured in a transistor geometry with and without gating, will be presented.

4:00pm **2D+EM+MC+MS+NS-MoA6 Avalanche Photodiodes based on MoS_2/Si Heterojunctions, Oriol López Sánchez, Ecole Polytechnique Fédérale de Lausanne (EPFL), Switzerland, G. Fiori, G. Iannaccone, Università di Pisa, Italy, D. Dumenco, Ecole Polytechnique Fédérale de Lausanne (EPFL), Switzerland, E. Charbon, Delft University of Technology, Netherlands**

Avalanche photodiodes (APDs) are the semiconducting analogue of photomultiplier tubes offering very high internal current gain and fast response. APDs are interesting for a wide range of applications in communications, laser ranging, biological imaging, and medical imaging where they offer speed and sensitivity superior to those of classical p-n junction-based photodetectors. The APD principle of operation is based on photocurrent multiplication through impact ionization in reverse-biased p-n junctions. Here, we demonstrate APDs based on vertically stacked monolayer MoS_2 and p-Si, forming an abrupt p-n heterojunction. With this device, we demonstrate carrier multiplication exceeding 1000 at 10 V reverse bias. Our devices show little degradation of SNR at high gains. These heterostructures allow the realization of simple and inexpensive high-performance and low-noise photon counters based on transition metal dichalcogenides.

4:20pm **2D+EM+MC+MS+NS-MoA7 From Black Phosphorus to Phosphorene, Peide Ye, Purdue University** **INVITED**

Phosphorus is one of the most abundant elements preserved in earth, constructing with a fraction of ~0.1% of the earth crust. In general, phosphorus has several allotropes. The two most commonly seen allotropes, white and red phosphorus, are widely used in explosives and safety matches. In addition, black phosphorus, though rarely mentioned, is a layered semiconductor and has great potentials in optical and electronic applications. Remarkably, this layered material can be reduced to one single atomic layer in the vertical direction owing to the van der Waals structure, known as phosphorene, where the physical properties can be tremendously different from its bulk counterpart. In this talk, we trace back to the 100 years research history on black phosphorus from the synthesis to material properties, and extend the topic from black phosphorus to phosphorene. The physical and transport properties are highlighted, aiming at further applications in electronic and optoelectronics devices.

5:00pm **2D+EM+MC+MS+NS-MoA9 Ambient Oxidation and Alumina Passivation of Exfoliated Black Phosphorus Transistors, Joshua Wood, S. Wells, D. Jariwala, K.-S. Chen, X. Liu, V. Sangwan, E. Cho, L. Lauhon, T.J. Marks, M.C. Hersam, Northwestern University**

Exfoliated black phosphorus (BP) is an elemental, two-dimensional (2D) nanomaterial with high carrier mobility ($\sim 100 \text{ cm}^2 \text{V}^{-1} \text{s}^{-1}$), a layer-dependent band gap (~ 0.3 to 2.0 eV), and in-plane anisotropy. Further, 2D BP is air sensitive, culminating in undesirable surface reactions that degrade device performance. We find that unencapsulated, exfoliated BP flakes form oxidized derivatives following ambient exposure, as ascertained by X-ray photoelectron spectroscopy, atomic force microscopy, Fourier transform infrared spectroscopy, transmission electron microscopy, and electrostatic force microscopy measurements. BP ambient oxidation is driven by oxygen-saturated H_2O , as we observe two-fold faster degradation for BP on hydrophobic substrates versus hydrophilic ones. After 48 hours of ambient oxidation, unencapsulated BP field-effect transistors (FETs) decline in mobility and current on/off ratio by factors of over 1000. In contrast, alumina (i.e., AlO_x) passivated BP flakes and FETs are robust and unoxidized for over seven months in ambient conditions. Alumina-passivated BP FETs possess mobilities of $\sim 100 \text{ cm}^2 \text{V}^{-1} \text{s}^{-1}$, on/off ratios of 1000, and ambipolar transport, even following extensive ambient exposure [1]. This understanding of BP ambient oxidation—and how to prevent it—is also impacting ongoing work in solution-phase BP separation [2], BP chemical modification, and high-performance BP optoelectronic applications.

[1] J. D. Wood *et al.*, *Nano Lett.* **14**, 6964 (2014); [2] J. Kang *et al.*, *ACS Nano* **9**, 3596 (2015).

5:20pm **2D+EM+MC+MS+NS-MoA10 Electro-Acoustic Characterization of Transition Metal Dichalcogenide Films on LiNbO_3 , Edwin Preciado, UC Riverside, F.J.R. Schülein, A. Wixforth, Universität Augsburg, Germany, A. Nguyen, D. Barroso, M. Isarraraz, G. von Son, I. Lu, L. Bartels, UC Riverside, H. Krenner, Universität Augsburg, Germany**
We demonstrate mm-scale CVD growth of single layer molybdenum disulfide directly onto piezoelectric lithium niobate and present the fabrication of a hybrid FET – SAW (field effect transistor – surface acoustic

wave) device. Our experiments reveal close agreement between transport measurements utilizing conventional contacts and SAW spectroscopy. This approach will ultimately provide for a contact free transport characterization of 2D TMD films, avoiding concerns about the role of charge transfer at contacts as an artifact of such measurements.

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